

Energy-efficient bifunctional CoB_x/GDY catalyst for urea-assisted hydrogen production via electrochemical urea oxidation and hydrogen evolution

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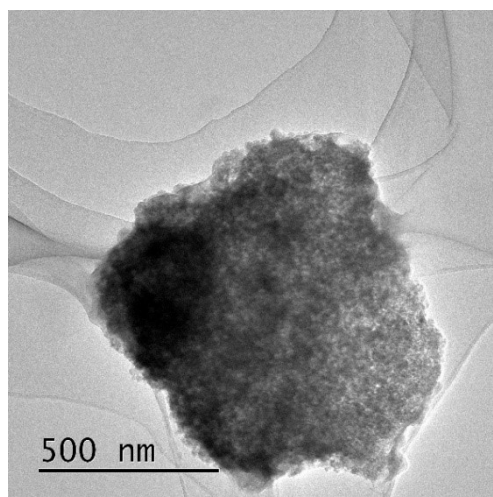


Figure S1. TEM image of CoB_x/GDY .

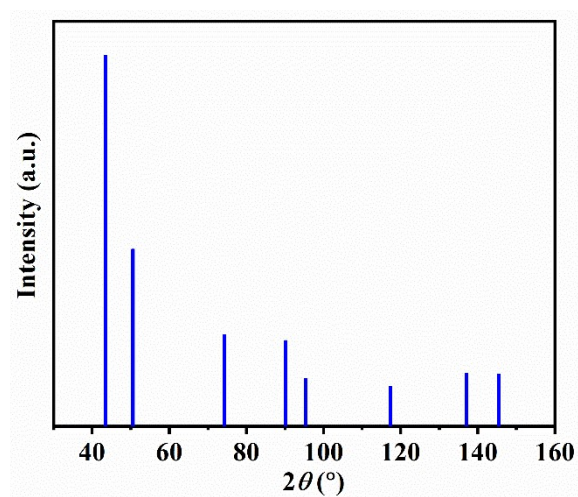


Figure S2. The standard diffraction pattern of metallic Cu (JCPDS card No. 65-9743).

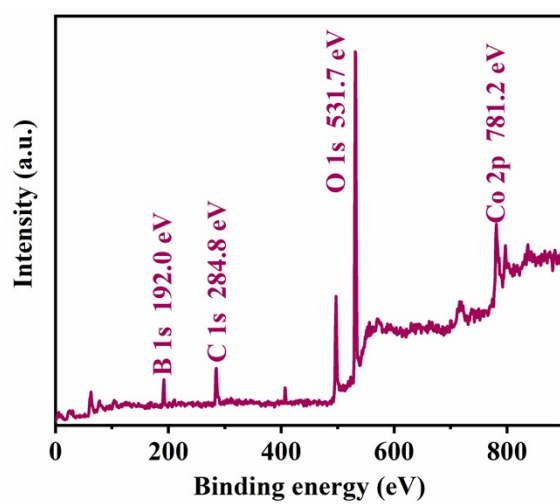


Figure S3. XPS wide survey spectrum for CoB_x/GDY.

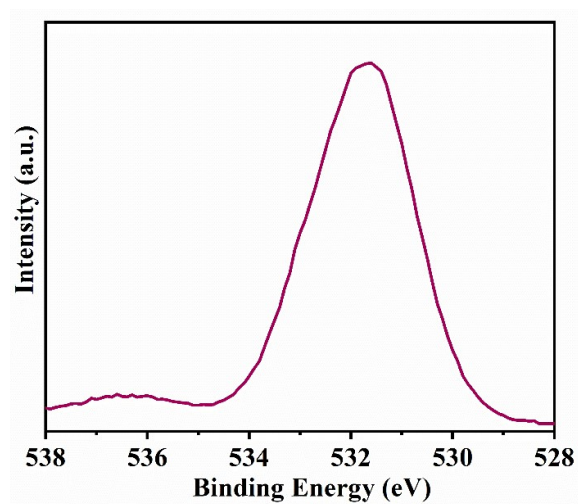


Figure S4. XPS spectrum of CoB_x/GDY in the O 1s region.

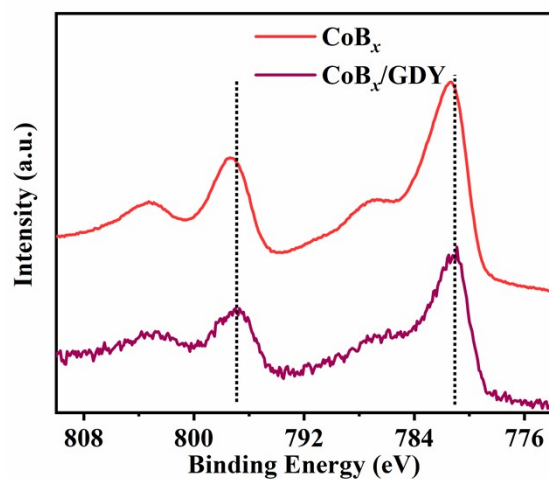


Figure S5. High-resolution Co 2p XPS spectra of CoB_x and CoB_x/GDY .

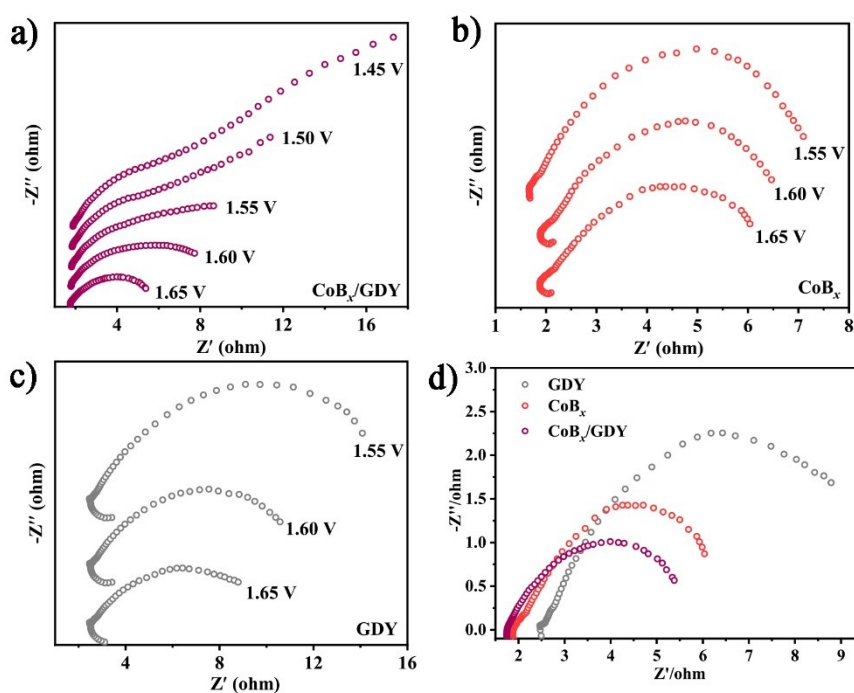


Figure S6. (a-c) Nyquist plots of CoB_x/GDY , CoB_x , and GDY at different operating potentials; (d) Nyquist plots of CoB_x/GDY , CoB_x , and GDY at 1.65 V.

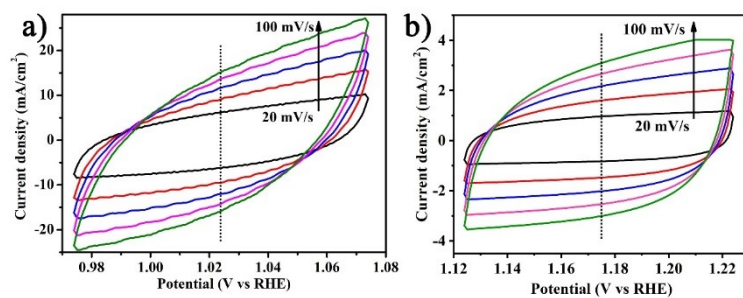


Figure S7. Typical CV curves for CoB_x/GDY (a) and CoB_x (b).

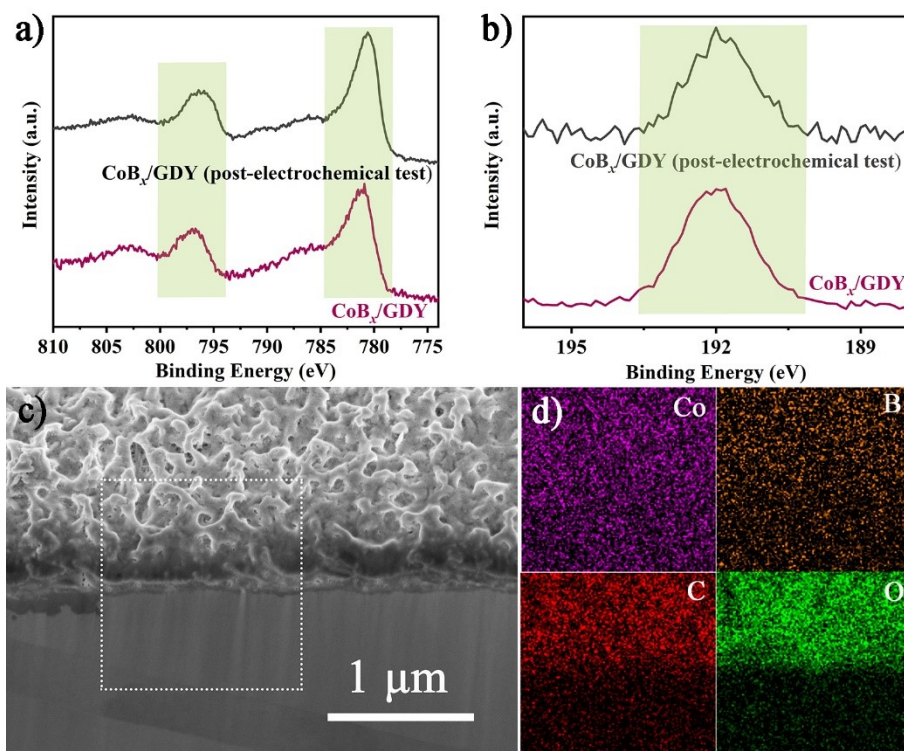


Figure S8. (a, b) Co 2p and B 1s XPS patterns of as-prepared CoB_x/GDY and the CoB_x/GDY after long-term electrolysis. (c, d) FIB-SEM image of CoB_x/GDY and the corresponding EDS elemental mapping (within the white-boxed region), showing the distribution of Co (purple), B (orange), O (green), and C (red).

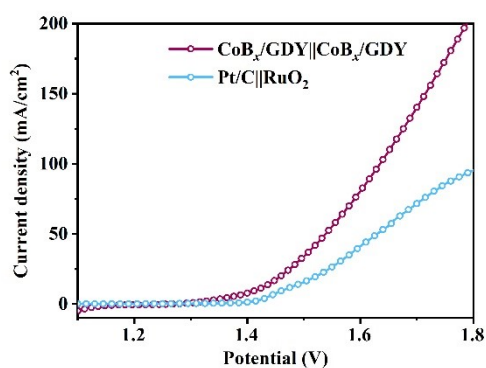


Figure S9. LSV curves of CoB_x/GDY||CoB_x/GDY and Pt/C||RuO₂ electrolyzers recorded in 1 M KOH containing 0.33 M urea.

Table S1. UOR performance of representative electrocatalysts (η_{10} , η_{50} , and η_{100} : potential at 10, 50, and 100 mA·cm⁻², respectively) and their corresponding Tafel slopes.

Catalysts	Electrolyte	η (V)	Tafel Slope (mV·dec ⁻¹)	References
CoB _x /GDY	1.0 M KOH + 0.33 M urea	η_{10} =1.26 V	58	This work
		η_{50} =1.41 V		
		η_{100} =1.49 V		
NiOOH/(LDH/ α -FeOOH)	1.0 M KOH + 0.33 M urea	η_{10} =1.35 V	30.1	1
		η_{50} =1.37 V		
		η_{100} =1.4 V		
V2-Ni(OH) ₂	1 M KOH+0.33 M urea	η_{100} =1.47 V	29.12	2
Ni-WO _x	1 M KOH + 0.33 M urea	η_{100} =1.40 V	39	3
Co-Ni-S@NF	1 M KOH + 0.33 M urea	η_{100} =1.35 V	29.6	4
Ru-Co DAS/NiO	1 M KOH + 0.33 M urea	η_{10} =1.29 V	23.3	5
CC/Ni-BDC@Co-PA	1 M KOH + 0.33 M urea	η_{100} =1.36 V	45	6
Ni _{1.6} Co _{0.4} P/C@HCNs	1 M KOH + 0.33 M urea	η_{10} =1.33 V	74.6	7
NF/P-NiMoO _{4-x}	1 M KOH + 0.33 M urea	η_{10} =1.36 V	19.3	8
		η_{100} =1.38 V		
O-NiMoP/NF	1 M KOH + 0.5 M urea	η_{100} =1.41 V	34	9
Co _x Mo _y S-CC	1 M KOH + 0.5 M urea	η_{10} =1.31 V	—	10
Co(OH)F/NF	1 M KOH + 0.7 M urea	η_{10} =1.25 V	—	11
FeCo/CoFe ₂ O ₄ @NGC	1 M KOH + 0.33 M urea	η_{10} =1.32 V	42.31	12
Cu ₃ P-P/CF	1 M KOH + 0.33 M urea	η_{10} =1.43 V	33.1	13
HC-Co(H ₂ PO ₂) ₂	1 M KOH + 0.33 M urea	η_{10} =1.30 V	35	14
		η_{10} =1.34 V		
FeOOH@Co ₃ O ₄	1 M KOH + 0.33 M urea	η_{10} =1.33 V	29	15
		η_{10} =1.38 V		
Fe ₃ O ₄ @FeOOH	1 M KOH + 0.33 M urea	η_{50} =1.42 V	28	16
		η_{100} =1.46 V		

Co ₂ P/NiMoO ₄ /NF	1 M KOH + 0.5 M urea	$\eta_{10}=1.34$ V	75	17
Ru/FeOOH@NFF	1 M KOH + 0.33 M urea	$\eta_{10}=1.41$ V	33	18
Cu ₃ P@CuO _x	1 M KOH + 0.33 M urea	$\eta_{10}=1.37$ V	29	19
		$\eta_{10}=1.30$ V		
Ru _{0.4} CoP-NC	1 M KOH + 0.33 M urea	$\eta_{50}\approx 1.41$ V	97	20
		$\eta_{100}\approx 1.47$ V		
CoMoO ₄ /Co ₉ S ₈	1 M KOH + 0.5 M urea	$\eta_{100}\approx 1.50$ V	22	21

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